

In the Specification:

Amend the paragraph at page 6, lines 1-7 as follows:

In an example embodiment of the present invention, the photoresist used on workpiece 40 to provide the required photosensitivity is a negative-tone dry film photoresist, which typically include a thin-film protective coating. An example of such a photoresist is RISTON[®] manufactured by DUPONT, which includes a thin MYLAR[®] coating that is transparent to the exposure wavelength of radiation. In the case of a MYLAR[®] -coated resist, the ink used should be one that readily adheres to and dries quickly on MYLAR[®]. MYLAR[®] is a trademark of a polyethylene terephthalate polyester film.